

APPLICATION DATA SHEET**Inventor Information**

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Country of Residence	:	United States of America
Citizenship Country	:	United States of America

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## Application Information

**Title** : METHOD FOR ENHANCING VERTICAL GROWTH  
DURING THE SELECTIVE FORMATION OF SILICON,  
AND STRUCTURES FORMED USING SAME  
  
**Total Drawing Sheets** : 2  
**Formal Drawings** : YES  
**Application Type** : Utility  
**Attorney Docket Number** : 500803.02  
**Assigned** : Yes (Large Entity)

## Representative Information

Representative Customer No. : 27.076

## Continuity Information

This application is a : divisional of  
>Application One : 09/770,909  
Filing Date : January 26, 2001

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